IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No	
Filing Date	
Confirmation No	
Inventor	Chapek, David L.
Assignee	Micron Technology, Inc.
Group Art Unit	2815
Examiner	Kim, Jay C.
Attorney's Docket No	
Title: Semiconductor Devices Including a Layer of Polycrystalline Silicon	
Having a Smooth Morphology	· · · · ·

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

References - - See attached Form PTO/SB/08A-B

The attached Form PTO/SB/08 is submitted In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, and your attention is directed to the references listed on the attached Form PTO/SB/08. No copies of any cited U.S. patents or U.S. published applications are included herewith. Copies of all other cited art are attached. No admission is made regarding whether all the submitted references are prior art.

The fee of \$180.00 is being charged to the credit card information provided electronically.

Citation of these references is respectfully requested.

Respectfully submitted,

Mark S. Matkin Reg. No. 32268